

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#2

In re application of: XSIL TECHNOLOGY LIMITED

Serial No. Art Unit

Filed: Examiner:

For: LASER MACHINING

Assistant Commissioner for Patents
 Washington, D.C. 20231
 USA

Sir,

INFORMATION DISCLOSURE STATEMENT

In the interests of candor, the Applicants wish to draw the Examiner's attention to following prior art of which Applicants have become aware.

Application no. (NAME), date

US 5 266 532	RUSSELL ET AL	11-30-1993
US 5 322 988	RUSSELL ET AL	07-21-1994
US 5 385 633	RUSSELL ET AL	01-31-1995
US 5 348 609	RUSSELL ET AL	09-20-1994
US 5 164 324	RUSSELL ET AL	11-17-1992
US 3 866 398	VERNON, JR, ET AL	02-18-1975
US 2002/050489	HAYASAKA NOBUO ET AL	05-02-2002
JP 61-140396	FUJIKURA	06-27-1986
WO 03 000456	SEPPELT KONRAD; POPKOVA	01-03-2003
	VERA YAKOVLEVNA; SHAFEEV	
	GEORGII	
WO 03 028943 A	LAMBDA PHYSIK APPLIC	04-10-2003
	CT L L C	
WO 03 028941 A	SCAGGS MICHAEL J	04-10-2003
WO 97,24768	PACIFIC SOLAR PTY LTD;	07-10-1997
	YOUNG TREVOR	

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WO 95 07152 A HOLLMAN RICHARD F; 03-16-1995
ELLIOTT DAVID J; SINGER
DANIEL K; UVT

Patents Abstract of Japan, vol. 009, no 100 2 May 1985 & JP 59 225896 A (Handoutai Enerugii Kenkyusho: KK) 18 December 1984

Lim P et al, "Laser-assisted liquid film etching", Applied Physics Letters, American Institute of Physics. New York, US, vol. 62, no. 25, 21 June 1993

Database WPI, Section CH, Week 198637, Derwent Publications Ltd., London, GB; Class L03, AN 1986-240798 & JP 61 053731 A (Anritsu Electric Co Ltd), 17 March 1986

Svorcik V et al, "Laser-stimulated etching of n-Si in Aqueous Solutions", Materials Letters, North Holland Publishing Company. Amsterdam, NL. Vol. 9, no.5/6, 1 March 1990,

Patents Abstract of Japan, vol. 012, no. 330 (E-655), 7 September 1988 & JP 63 094657 A (NEC CORP), 25 April 1988

The relevance of the references is as indicated in the attached International and GB Search Reports.

The above references are listed on the attached Form PTO/SB/08A and the Examiner is respectfully requested to make them of record.

Respectfully submitted

Date: Jan Feb. 7, 2005

By: D. S. Rupert
Douglas S Rupert
Reg. No. 44,434

**Examiner
Signature**

Please type a plus sign (+) inside this box → ☐

PTO/SB/08A (08-00)

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**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

(use as many sheets as necessary)

Sheet

of

Attorney Docket Number

Complete if known **104523846**

Application Number

Filing Date

First Named Inventor

BOYLE, Adrian

Group Art Unit

Examiner Name

OTHER PRIOR ART -- NON PATENT LITERATURE DOCUMENTS

Examiner Initials *	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
		Patent Abstracts of Japan, vol. 009, no. 100 (M-376), 2 May 1985 & JP 59 225896 A (HANDOUTAI ENERUGII KENKYUSHO: KK), 18 December 1984	
		LIM P ET AL, "Laser-Assisted Liquid Film Etching", Applied Physics Letters, American Institute of Physics, New York, US, vol. 62, no.25, 21 June 1993, pages 3345-3347, XP000380997, ISSN: 0003-6951, page 3345	
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		SVORCIK V ET AL: "Laser-Stimulated Etching of N-Si in aqueous solutions" Material Letters, North Holland Publishing Company, Amsterdam, NL, vol.9, no.5/6, 1 March 1990, pages 204-206 XP000127337, ISSN: 0167-577X, the whole document	
		Patents Abstracts of Japan, vol. 012, no. 330 (E-655), 7 September 1988 & JP 63 094657 A (NEC CORP), 25 April 1988,	

Examiner
SignatureDate
Considered¹ EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.² Unique citation designation number. ² Applicant is to place a check mark here if English language Translation is attached.

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